



**INFORMATION DISCLOSURE  
CITATION FORM FOR  
PATENT APPLICATION  
(FORM PTO-1449)  
(Substitute)**

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Applicant(s): Sami Haapoja

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**U.S. PATENTS**

Initials	Patent Number	Issue Date	Name	Class	Sub-class	Filing date
VLL	6,023,609	2/8/00	Futamura	455	82	11/18/97

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Technology Center 2600

**U.S. PATENT PUBLICATIONS**

Initials	Publication No.	Pub. Date	Name	Class	Sub-class	Filing Date

**FOREIGN PATENT DOCUMENTS**

Initials	Document Number	Date	Country	Name	Translation? Yes/No/n/a
VLL Nile	EP 0 481 825 A2	4/22/92	Europe	Sony Corporation	n/a
	GB 2 346 049 A	7/26/00	United Kingdom	Roke Manor Research Limited	n/a

**OTHER DOCUMENTS (Title, Author, Date, Pages, Etc., if known)**


Examiner's Signature: *N. Kwon*Date Considered: *03/15/04*

Initial if reference was considered, whether or not citation is in conformance with MPEP. Mark through citation if not considered.

Include a copy of this citation form with your next correspondence to the Applicant(s).